Planar Hot-Electron Photodetection with Tamm Plasmons

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ABSTRACT: There is an increasing interest in harvesting photoejected hot-electrons for sensitive photodetectors, which have highly tunable detection wavelengths controlled by structural engineering rather than the classic doped semiconductors. However, the widely employed metallic nanostructures that excite surface plasmons (SPs) to enhance the photoemission of hot-electrons are usually complex with a high fabrication challenge. Here, we present a purely planar hot-electron photodetector based on Tamm plasmons (TPs) by introducing a distributed Bragg reflector integrated with hot-electron collection layers in metal/semiconductor/metal configuration. Results show that the light incidence can be strongly confined in the localized region between the top metal and the adjacent dielectric layer due to the excitation of TP resonance so that more than 87% of the light incidence can be absorbed by the top metal layer. This enables a strong and unidirectional photocurrent and a photoresponsivity that can even be higher than that of the conventional nanostructured system. Moreover, the planar TP system shows a narrow-band resonance with high tunability, good resistance against the change of the incident angle, and the possibility for extended functionalities. The proposed TP-based planar configuration significantly simplifies the conventional SP-based systems and opens the pathway for high-performance, low-cost, hot-electron photodetection.

KEYWORDS: Tamm plasmons, surface plasmons, hot electrons, photodetector, photoresponsivity

Energetic hot electrons excited through photon absorption in metals can be extracted via internal photoemission for a number of applications, e.g., photodetection,1−5 photovoltaics,6,7 photocatalysis,8,9 and surface imaging.10,11 In terms of photodetection, the hot-electron mechanism enables direct and efficient below-bandgap photodetection, high tunability of the working wavelength by manipulating the structured resonance instead of the materials, and the possibility of room-temperature operation.12,13 Indeed, direct illumination on a metal film can excite hot electrons but with an extremely low efficiency due to the lack of effective light-trapping mechanisms.14,15 Surface plasmons (SPs) provide an interesting solution because they can strongly localize the photon energy within a deep-subwavelength region where extensive hot electrons can be generated.16−20 Nevertheless, almost all of the existing SP-based hot-electron devices employ metal/dielectric hybrid systems with delicately designed nanostructures,21−27 which normally have in-plane subwavelength (or deep-subwavelength) patterns and require complicated/costly fabrications.23 Therefore, part of the attention goes back to the planar scenarios for cost-effective strategies. Unfortunately, planar systems are normally not good at trapping light unless the one-dimensional multilayer system has been carefully designed. For example, it was demonstrated that, by integrating the metal/semiconductor/transparent conductive oxide (TCO) junction into an asymmetric microcavity, the optical absorption in metal can be substantially enhanced.28 However, the microcavity system needs two distributed Bragg reflectors (DBRs), leading to a relatively thick device, which also results in a challenge for fabrication.

Recently, a type of SP named Tamm plasmons (TPs), which are also called optical Tamm states, formed at the boundary between a metal and the adjacent dielectric layer due to the excitation of TP resonance so that more than 87% of the light incidence can be absorbed by the top metal layer. This enables a strong and unidirectional photocurrent and a photoresponsivity that can even be higher than that of the conventional nanostructured system. Moreover, the planar TP system shows a narrow-band resonance with high tunability, good resistance against the change of the incident angle, and the possibility for extended functionalities. The proposed TP-based planar configuration significantly simplifies the conventional SP-based systems and opens the pathway for high-performance, low-cost, hot-electron photodetection.

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propagating along the metal/DBR interface can be highly confined in the region around the metal/dielectric interface, allowing for strong absorption by the metal layer.\textsuperscript{32} In contrast to SPs, with the assistance of the DBR, TPs in planar systems can be efficiently excited from free space without any polarization discrimination and thus can find very broad applications,\textsuperscript{33} including photovoltaics,\textsuperscript{34} sensors,\textsuperscript{35}−\textsuperscript{37} polariton lasers,\textsuperscript{38} detectors\textsuperscript{39} and optical switches.\textsuperscript{40} Here, we report a TP-based hot-electron photodetector (TP-HE PD), in which a properly engineered DBR is integrated with the metal/semiconductor/metal (MSM) hot-electron layers. With strong coupling of the band-engineered DBR and the MSM HE cavity, an intensive TP resonance can be excited with high tunability in a broad spectral range and good tolerance against variation of the incident angle. Electromagnetic simulation predicts a near-unity optical absorption at the TP resonance and more than 87\% absorption by the top metal layer, allowing for strongly asymmetric optical absorption for a high unidirectional photocurrent. Moreover, the purely planar and thin metallic design facilitates the hot-electron transport in the device such that high photoresponsivity, over 2 times that based on the conventional grating-coupled SP-HE PD system, can be achieved. We believe that the planar hot-electron photodetection system based on the excitation of TPs could be a promising candidate for low-cost and sensitive hot-electron photodetection applications.

We first provide a brief review of Tamm plasmons excited from the special planar systems. TPs are tightly confined electromagnetic states at the boundary between a metal and a DBR in analogy with electron states predicted by Tamm in condensed matters.\textsuperscript{29} In contrast to conventional SPs, the wave vector of TPs lies inside the light cone given by $k = \omega/c$, where $k$ is the in-plane wave vector and $\omega$ is the angular frequency. Therefore, TPs can be optically excited from free space under any polarizations without needing the vector-matching treatments by gratings, nanoparticles, or prisms. To illustrate how the electromagnetic field is confined by TPs, we consider the planar multilayer structure comprising a front DBR and a semi-infinite Au layer as shown in the inset of Figure 1a. The DBR consists of 8 pairs of alternating Al$_2$O$_3$/TiO$_2$ layers (each layer with quarter-wavelength optical thickness, where the DBR central wavelength $\lambda_{DBR}$ is initially considered to be 750 nm). The thicknesses of the bottom TiO$_2$ layer and top Au layer are defined as $d_{TiO2}$ and $d_{Au}$, respectively.

Figure 1. (a) Profile of the normalized electric field $|E|^2$ along $z$ axis for a TP at the interface between a front 8-pair DBR and a semi-infinite Au layer. The schematic of the classic Tamm structure (DBR+M) is shown in the inset. (b) Reflection spectra $R(\lambda)$ of the bare DBR and DBR+M structures. (c) Reflection spectra $R(\lambda)$ of the TP-based hot-electron photodetector (TP-HE PD) with the corresponding schematic diagram inserted. (d) Energy band diagram of TP-HE PD. Unless specifically indicated, the thicknesses of the top Au, intermediate ZnO, and bottom Au layers are 25, 5, and 200 nm, respectively; the DBR consists of 8 pairs (DBR pair number $N_{DBR} = 8$) of alternating Al$_2$O$_3$/TiO$_2$ layers (each layer with quarter-wavelength optical thickness, where the DBR central wavelength $\lambda_{DBR}$ is initially considered to be 750 nm). The thicknesses of the bottom TiO$_2$ layer and top Au layer are defined as $d_{TiO2}$ and $d_{Au}$, respectively.

RESULTS AND DISCUSSION

Figure 1c shows a schematic of the proposed TP-HE PD under the planar configuration, which is composed of the silica substrate, MSM stack, and DBR. Here, M+DBR is used to excite the TP in the M/DBR interface,\textsuperscript{29−31} and MSM is used to collect the generated hot electrons.\textsuperscript{27,28} Unless specifically indicated, the thicknesses of the top metal (Au), intermediate semiconductor (ZnO), and bottom metal (Au) layers are 25, 5, and 200 nm.
and 200 nm, respectively; the DBR pair number ($N_{\text{DBR}}$), DBR central wavelength ($\lambda_{\text{DBR}}$), and layer thicknesses of DBR are inherited from Figure 1a. Differing from the conventional metal/semiconductor devices based on Schottky junctions, the semiconductor used here is intrinsic; therefore, it is just a modified MIM (I: insulator) system under the same operation principle.\(^{13}\) The employment of the wide-bandgap (3.3 eV)\(^{41}\) semiconductor used here is intrinsic; therefore, it is just a metal/semiconductor devices based on Schottky junctions, the barrier. Moreover, Figure 1c shows that the special design range as well as facilitates the hot-electron transport through the barrier. Moreover, Figure 1c shows that the special design of MSM+DBR allows an extremely low reflection dip by the device (device transmittance is zero with the presence of the rear Au reflector), affording a greatly strengthened TP. It is noted that the thickness of the top Au layer ($t_{\text{Au}}$, adjacent to the DBR) is much smaller than the mean free path (MFP) of electrons in Au ($\sim$40 nm for low-energy electrons)\(^{44}\) to ensure a high probability for the generated hot electrons to reach the M/S interface before thermalization and finally accomplish the interfacial electron transfer process.\(^{45}\) Moreover, it is crucial that TiO$_2$ ($t_{\text{TiO}_2}$, the high-index layer) be the layer adjacent to the MSM to ensure the excitation of TPs.\(^{29}\) For convenience of the discussion, the thicknesses of the bottom TiO$_2$ layer and top Au layer are defined as $d_{\text{TiO}_2}$ and $d_{\text{Au}}$, respectively.

Hot electrons are generated through the nonradiative decay of plasmon resonances, thermalized by electron-electron scattering in tens of femtoseconds (10–100 fs) after excitation, and subsequently cooled via energy transfer to the lattice by electron-phonon scattering picoseconds later (100 fs to 1 ps). Ultimately, the lattice phonons come to equilibrium with the surroundings of the metallic structure on the 100 ps time scale.\(^{7,19}\) The performance of the TP-HE PD can be determined by considering the following consecutive processes as depicted by the energy band diagram shown in Figure 1d.\(^{13}\)

Upon generation via illumination and TP resonances, half of the generated hot electrons will diffuse toward the M/S interface, but only a fraction of them will reach the interface without losing energy in an inelastic collision. Moreover, the generated hot electrons by the top Au layer must propagate across the ultrathin intermediate ZnO layer and finally be collected by the opposite contact. To obtain the device photocurrent, we need to calculate the probability of the generated hot electrons to be injected into the semiconductor, propagate across the semiconductor, and be collected by the opposite electrode. For the MSM system, there are two counter-propagating electron flows from both electrodes so that the net photocurrent determines the overall performance of the system. This condition requires a strongly asymmetric absorption in the top and bottom Au layers.\(^{25}\) In the following discussion, the detailed optical and electrical performances will be studied.

Before the electrical evaluation of the TP-HE PD, the optical performance (light-trapping capability) has to be examined. On the basis of the optical constants from Palik,\(^{45}\) rigorous coupled-wave analysis (RCWA) is first employed to study the optical dispersion characteristics to properly configure the device for the excitation of TP resonance.\(^{46}\) The reasons to use RCWA are as follows: (1) it is computationally efficient for a large range of parametrical optimizations, and (2) it can be readily extended to nanostructured systems (e.g., multilayered grating systems) in the future. The detailed optical response including the electric field distribution and the optical absorption by each layer is analyzed by solving Maxwell’s equations via the finite-element method (FEM).\(^{47}\) Following the same procedures, when introducing other materials, the measured frequency-dependent dielectric constant can be used in RCWA and FEM. Taking into account the resistive loss ($P_{\text{resistive}} \approx 30\%$) of the absorbed energy, which is dissipated

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**Figure 2.** Dependences of the device reflection $R(\lambda)$ on (a) the DBR pair number $N_{\text{DBR}}$, (b) the bottom TiO$_2$ thickness $d_{\text{TiO}_2}$ in DBR, and (d) the DBR central wavelength $\lambda_{\text{DBR}}$. (c) Absorption and reflection of the entire TP-HE PD at TP wavelength $\lambda_{\text{TP}} = 813$ nm vs $N_{\text{DBR}}$. (d) Enlarged figure showing the TP area from (a). The rest of the parameters are the same as those indicated in the caption of Figure 1.
without hot-electron generation due to the intrinsic lifetime of the electronic states comprising the collective oscillation, the spatially dependent hot-electron generation rate \( G \) can be written as

\[
G(x, z, \omega) = (1 - P_{\text{resitive}}) e_i |E(x, z, \omega)|^2 / (2\hbar)
\]

where \( \omega \) is the angular frequency, \( e_i \) the imaginary part of the material permittivity, \( E(x,y,z) \) the electric field at position \((x,y,z)\), and \( \hbar \) the reduced Planck constant. For calculations of the absorption efficiency \( A \) and detailed derivation of hot-electron generation rate, refer to section 1 of the Supporting Information.48

With confirmation of the excitation of strong TP by DBR + MSM as shown in Figure 1c, we now investigate (1) how to obtain the strongest TP by properly controlling the number of DBR pairs \( N_{\text{DBR}} \) \( \) [Figure 2a and c] and (2) how to tune the resonance by engineering the thickness of the bottom TiO2 layer \( d_{\text{TiO2}} \) \( \) [Figure 2b] or the central wavelength of DBR \( \lambda_{\text{DBR}} \) \( \) [Figure 2c]. Figure 2a exhibits a dark reflection spot (indicating the excitation of TPs) appearing in the optically forbidden band of the DBR. Moreover, it is revealed that the parameter \( N_{\text{DBR}} \) has a strong impact on the reflection characteristics of the device. When the DBR layers are too few, most of light is reflected back due to the high reflectance of the rear Au reflector; however, with a large \( N_{\text{DBR}} \), most of light is reflected directly by DBR without entering the system. Therefore, a proper \( N_{\text{DBR}} \) is crucial for the realization of a strong TP. These can be easily seen from Figure 2c, which plots the device reflection at the TP wavelength \( (\lambda_{TP} = 813 \text{ nm}) \) as a function of \( N_{\text{DBR}} \) where the reflection of a bare DBR at the same wavelength is shown for reference. A deeper analysis regarding the effect of \( N_{\text{DBR}} \) and the field confinement of TPs in the proposed TP-HE PD can be found in section 2 of the Supporting Information.

On the other hand, the tunability of TP resonance can be realized by adjusting \( d_{\text{TiO2}} \) \( \) [Figure 2b] or \( \lambda_{DBR} \) \( \) [Figure 2d]. It is clear from Figure 2b that, by controlling \( d_{\text{TiO2}} \), TP resonance can be tuned to occur at any wavelength in the DBR forbidden band. However, \( \lambda_{TP} \) does not show a linear dependence on \( d_{\text{TiO2}} \) due to the cavity and material dispersion. The interval between two neighboring TP resonances for a given wavelength \( \lambda \) is \( \lambda/2n \) (refractive index \( n = 2.4 \) for TiO2). Figure 2d shows that \( \lambda_{TP} \) increases almost linearly with \( \lambda_{DBR} \) which is consistent with the prediction when the Bragg frequency \( (\hbar \omega_0 = 1.65 \text{ eV}) \) is much lower than the plasma frequency of gold \( (\hbar \omega_p = 8.9 \text{ eV}) \). These observations show that the TP resonance can be tuned in a wide spectral range, which covers the visible or even the near-infrared bands for hot-electron photodetection.

The detailed optical response of TP-HE PD is plotted in Figure 3a. It is shown that (1) at the TP resonance, the reflection of the device is negligible \( (R \approx 1.6\%) \), whereas for the off-resonance cases, nearly the entire incidence is reflected back by the highly reflective DBR, (2) over 87% of the light is absorbed preferentially by the top Au layer due to the excitation of TP at the MSM/DBR interface, and (3) compared to the top Au layer, the bottom Au layer shows a much weak absorption \( (\sim 10.6\%) \), ensuring an asymmetrical optical absorption. For comparison, Figure S2a presents the results for the conventional grating-based SP-HE PD in which the thicknesses of the top Au, ZnO, and bottom Au layers are identical to those of the TP-HE PD shown in Figure 3a; in this case, the key parameters to determine the resonant wavelength are the period and width of the grating, which are identified to be 800 and 280 nm, respectively, in order to excite SP resonance at the same wavelength \( (813 \text{ nm}) \). This indicates that the absorption in the

Figure 3. (a) Detailed optical responses. Spatial distributions of (b) the hot-electron generation rate, (c) transport probability, and (d) flux of hot electrons reaching the M/S interface before thermalization for excess energy of 0.9 eV. The device configuration of the TP-HE PD is inserted in (a). The device parameters used here are the same as those indicated in the caption of Figure 1.
Figure 4. (a) Initial energy distribution of hot electrons excited in Au by incident photons with a wavelength of 813 nm. The horizontal scale represents the excess electron energy with respect to Fermi energy, $E_F$. The final distribution of hot-electron energies accumulated at the top (b) and bottom (c) M/S interfaces considering the energy-dependent MFP. The responsivities of the TP- and SP-HE PDs as a function of (d) the electric bias $V_{app}$ and (e) the barrier height $\Phi_b$, where the device parameters are from Figure 1. The bottom (top) insets in (d) are the energy band diagrams at reverse/zero/forward bias (the corresponding IQE vs the bias). The inset in (e) is IQE vs the barrier height.

The initial hot electron energy distribution $D(E)$ can be written and normalized as \[ D(E) = \frac{\rho(E-h\nu)f(E-h\nu)\rho(E)[1 - f(E)]}{\int \rho(E-h\nu)f(E-h\nu)\rho(E)[1 - f(E)] dE} \] (2)

where $E$ is the energy of the excited electron, $h\nu$ the photon energy, $\rho(E-h\nu)$ [$\rho(E)$] the parabolic electron density of states at the initial [final] energy level, and $f(E-h\nu)$ [$f(E)$] the corresponding Fermi distribution function. On the basis of the assumption of an isotropic initial momentum distribution and using the exponential attenuation model, the probability that a hot electron reaches the M/S interface is evaluated by \[ P_1(x, z, E) = \frac{1}{2\pi} \int_0^{\pi/2} \exp \left( -\frac{d(x, z)}{\lambda(E)\cos \theta} \right) d\theta \] (3)

where $d$ is the distance from the generation position of the hot electrons to the M/S interface, $\theta$ the moving angle of hot electrons, and $\lambda(E)$ the energy-dependent MFP of hot electrons accounting for electron-electron and electron-phonon contributions. With the initial energy distribution $D(E)$ of hot electrons, the spatial distributions of the hot electron generation rate $G(x, z)$, and the energy-dependent transport probability $P_1(x, z, E)$, the flux of hot electrons reaching the top or the bottom M/S interface in the TP-based HE PDs can be written as

$N(x, z, E) = G(x, z) \times D(E) \times P_1(x, z, E)$ (4)

To compare extensively the internal photoemission efficiency of the hot-electron devices based on TPs and SPs, we take the electron with an excess energy ($E_d$) of 0.9 eV above the Fermi level as an example to depict the spatial distributions of the hot-electron generation rate as well as the probability and flux that the hot electrons reach the M/S interface before thermalization in Figure 3b–d and Figure S2c–d. It is found that (1) for the TP-HE PD, the hot electrons are predominantly generated in the top Au layer, which leads to a strong hot-electron flow from the top Au layer to the bottom. For the SP-HE PD, most hot electrons are generated in the region close to the upper surface (or the corners) of the top (bottom) Au layer; (2) for the TP device, the probability for the hot electrons near the M/S interface is as large as 0.5 and decreases with increasing distance from the M/S interface toward both terminals. Whereas for the grating system, not only the distance from the M/S interface but also the diffusion angle plays an important role. For example, $P_1$ in region 2 shown in the inset of Figure S2a is nearly zero as shown by Figure S2c. Accordingly, we can therefore see that some nanostructured systems might not take full use of the metal layers for hot-electron collection compared to that of the planar systems; (3) for the TP-based devices, because of the ultrathin top Au layer with a thickness comparable to the MFP ($\sim$21 nm for $E_d = 0.9$ eV) of electrons in Au, the hot electrons generated in the entire top Au layer have a high chance to reach the interface without essential relaxation. As a result, a large part of the hot electrons can participate in the interfacial electron transfer process and contribute to the detected photocurrent. Nevertheless, for the grating-based system, the flux of the hot electrons reaching the M/S interface is far less, as shown by Figure S2d.
The initial energy distribution of the hot electrons excited by the photons with wavelength of 813 nm is shown in Figure 4a, where the shaded area shows the proportion of hot electrons with energy above the Schottky barrier. After transportation, the final energy distributions of the hot electrons reaching the top and bottom M/S interfaces are provided in Figure 4b and c, respectively. Following the model based on accessing the emission probability and multiple reflection losses as a result of an impedance mismatch of electrons between metal and semiconductor, the probability for the hot electrons accumulated at the interface to be injected into the semiconductor can be expressed as

\[ N_{\text{hot}} = d \int \int \int N_{\text{hot-top}}(x, z, E) \times P(E)P_s(E)P(E) \, dx \, dz \, dE \]

where \( N_{\text{hot-top}} \) is the hot-electron flux reaching the top M/S interface.

Figure 4d shows the calculated photoresponsivities of the TP- and grating-based SP-HE PDs as a function of the applied voltage \( V_{\text{app}} \) at the resonant wavelength. The result indicates that the unbiased photoresponsivity of the TP-HE PD is as high as 13.7 nA/mW, which is over 2 times larger than that of the grating-based system (6.5 nA/mW). The underlying physics can be explained as follows. In the conventional grating-based HE PDs, although strong plasmonic resonance can be excited, the incident light can directly interact with (and be absorbed by) the bottom metal layer; however, in the TP systems, the incident light must interact with the top metal layer first with strong TP excitation such that the bottom metal absorption can be effectively suppressed. The strongly improved asymmetrical optical absorption in the TP system ensures the strongly improved photoresponsivity. The photoresponsivities of both devices can be further enhanced by applying a forward electric bias (positive/negative contact connects the bottom/top Au electrode), which promotes the kinetic energy of the hot electrons in the semiconductor and results in a higher transmission probability as illustrated by the inset in the left-top corner of Figure 4d. The photoresponsivities of both HE PDs relative to the barrier height are plotted in Figure 4e, where the corresponding IQE curves of the TP-HE PD have been inserted. It is found that the responsivity can be decreased by an order of magnitude with \( \Phi_0 \) increasing from 0.4 to 1.2 eV, which leads to decreased IQEs. In all positive biases and barrier situations, the photoresponsivities of the grating-based HE PD are lower than those of the TP system because these two systems show similar dependences on \( V_{\text{app}} \) and \( \Phi_0 \), whereas the TP system exhibits much better optical performance.

As both the eigenfrequency of TPs and the extraction efficiency of hot electrons are sensitive to the metal thicknesses, especially the thickness of the top Au layer \( d_{\text{Au}} \), the effect of \( d_{\text{Au}} \) on the optical and electrical responses are examined in Figure 5. The dependence of the TP resonance on \( d_{\text{Au}} \) is shown in Figure 5a, where the corresponding TP resonant wavelengths are given in the inset. It is observed that a thick-enough top Au layer (>50 nm) stabilizes the spectral position for TP excitation, as verified by a very distinct band of reflection dips. The detailed optical components, i.e., top Au absorption, bottom Au absorption, and device reflection, are shown in Figure 5b. It is found that (1) by using the DBR + MSM configuration, nearly all incident energy can be absorbed by the device under the TP mechanism and (2) a high net absorption requires a relatively thick top Au layer. However, the improved asymmetric optical absorption does not certainly lead to a high responsivity because the generated hot electrons in a thick Au layer suffer from high thermalization losses by electron–electron and electron–phonon scatterings. As a result, the optimal photoresponsivity occurs at \( d_{\text{Au}} \approx 20 \text{ nm} \).

We would like to also indicate that the highly sensitive photoresponsivity by TP-HE PD can be sustained simultaneously over a wide range of incident angles; moreover, the proposed TP-HE PD system can be extended to show rich functionalities, e.g., multiband photodetection. For a detailed discussion, refer to sections 4 and 5 of the Supporting Information.

Finally, we provide a detailed comparison with the existing measurements to show the validity of the modeling approach and the state-of-the-art hot-electron-based photodetectors. It is noted that the predicted performance is not that high compared with some of the previous designs. However, the key difference lies in the various system configurations (based on different
operation mechanisms) and operation wavelengths. For example, (1) for Schottky devices using a highly doped semiconductor, the quantum efficiency of MIM is relatively low, primarily due to additional reflection losses arising from the additional MI interface, and (2) the significant photogain in bilayer MoS2 with hot-electron injection shows a much higher efficiency. Whereas if we compare MIM-based devices, the responsivity of the TP-HE PD is comparable to or even higher than that (9 nA/mW) of the plasmonically enhanced hot-electron device. In addition, compared to the references with Au/Al2O3 contact, the responsivity in this study (i.e., 13.7 nA/mW) has been significantly improved compared to the references (i.e., responsivity <80 nA/W) due to a much lower barrier being formed in the Au/ZnO contact (ΦB = 0.9 eV) in this study.

CONCLUSIONS

In summary, we present a purely planar setup for hot-electron photodetection without employing the conventional highly nanostructured components. The TP-HE PD is composed of an MSM hot-electron stack integrated with a front DBR. Such a hybrid system can excite a very strong TP resonance, which confines the incident photon energy in a region very close to the top Au layer such that the highly asymmetric and strongly enhanced optical absorption can be realized to ensure a unidirectional hot-electron flow. In addition, the top Au layer and intermediate ZnO layer used are extremely thin to ensure high efficiency of the internal photoemission process. We extensively investigate the tunability and optimization of the TP excitation in the DBR-MSM hybrid system by controlling the DBR pair number, DBR central wavelength, bottom DBR thickness, and top Au thickness. Results indicate that the system has a very high tunability with a very broad range (long to infrared region) for the TP resonance, a good tolerance to the change of incident angle, and the possibility to realize extended functionalities of hot-electron photodetection. An optimized TP-HE PD exhibits a photoresponsivity that can be over 2 times that of the conventional grating-based HE PD. To conclude, the TP hot-electron strategy based on purely planar layers with even higher optoelectronic performance than that of the nanostructured equivalents shows great potential for compact, highly sensitive, and low-cost applications in photodetection, biosensing, and imaging.

METHODS

**Optoelectronic Simulation of the TP-HE PD.** Simulations are performed in this study by addressing both the electromagnetic and electrical responses of the TP-HE PD. The electromagnetic response is achieved by solving the Maxwell's equations via the finite-element method (FEM). The optical absorption, electrical field distribution, Tamm plasmon resonance, and so forth, can all be investigated. In the electrical treatment, the carrier generation rate is obtained by directly converting the absorbed photons into hot electrons. It further involves the calculation of the initial hot-electron energy distribution, the detailed hot-electron diffusion inside the metal layer, and the forthcoming hot-electron transportation processes through the MS interfaces and the semiconductor layer. The device photocurrent is obtained by calculating the downward and upward photocurrents based on the above optoelectronic simulation. A detailed description of the optoelectronic simulation method is provided in the Supporting Information.

**ASSOCIATED CONTENT**

* Supporting Information

The Supporting Information is available free of charge on the ACS Publications website at DOI: 10.1021/acsnano.6b07578.

Optoelectronic model, more about Tamm plasmons, analysis of SP-HE PD photoemission process, angular performance of TP-HE PD, and multiband hot-electron photodetection (PDF)

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**Author Contributions**

C.Z. carried out the design, organized the figures, and drafted the manuscript. K.W. contributed to the preliminary calculations. X.L. conceived the design and supervised (together with V.G.) the research. C.Z., X.L., and V.G. contributed to the revision of the manuscript and Supporting Information. All authors read and approved the final manuscript.

**Notes**

The authors declare no competing financial interest.

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